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DATE MAILED: 07/18/2006

| APPLICATION NO. | F | ILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO |
|--|------|------------|----------------------|---------------------|-----------------|
| 10/532,782 | · | 04/25/2005 | Kazuhide Kumakura | 14321.71 | 6664 |
| 22913 | 7590 | 07/18/2006 | | EXAM | INER |
| WORKMA | | | IVEY, ELIZABETH D | | |
| (F/K/A WORKMAN NYDEGGER & SEELEY) 60 EAST SOUTH TEMPLE | | | | ART UNIT | PAPER NUMBER |
| 1000 EAGLE GATE TOWER | | | | 1775 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | Application No. | Applicant(s) | | | | | |
|---|--|---|--|--|--|--|--|
| | Application No. | | | | | | |
| Office Action Commons | 10/532,782 | KUMAKURA ET AL. | | | | | |
| Office Action Summary | Examiner | Art Unit | | | | | |
| The MAILING DATE of this communication a | Elizabeth Ivey | 1775 | | | | | |
| The MAILING DATE of this communication a Period for Reply | ppears on the cover sheet wit | in the correspondence address | | | | | |
| A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory periodary reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the main earned patent term adjustment. See 37 CFR 1.704(b). | DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a rend will apply and will expire SIX (6) MONT ute cause the application to become ABA | CATION. sply be timely filed IHS from the mailing date of this communication. ANDONED (35 U.S.C. § 133). | | | | | |
| Status | | | | | | | |
| 1) Responsive to communication(s) filed on 18 | April 2006. | | | | | | |
| | nis action is non-final. | | | | | | |
| Since this application is in condition for allowance except for formal matters, prosecution as to the merits is | | | | | | | |
| closed in accordance with the practice unde | r <i>Ex parte Quayle</i> , 1935 C.D. | . 11, 453 O.G. 213. | | | | | |
| Disposition of Claims | | | | | | | |
| 4) Claim(s) 5-12 is/are pending in the application | ☑ Claim(s) <u>5-12</u> is/are pending in the application. | | | | | | |
| 4a) Of the above claim(s) is/are withd | 4a) Of the above claim(s) is/are withdrawn from consideration. | | | | | | |
| 5) Claim(s) is/are allowed. | | | | | | | |
| 6)⊠ Claim(s) <u>5-12</u> is/are rejected. | | | | | | | |
| 7) Claim(s) is/are objected to. | | | | | | | |
| 8) Claim(s) are subject to restriction and | d/or election requirement. | | | | | | |
| Application Papers | | | | | | | |
| 9)☐ The specification is objected to by the Exam | iner. | | | | | | |
| 10)⊠ The drawing(s) filed on <u>25 April 2005</u> is/are: | a)⊠ accepted or b)☐ object | cted to by the Examiner. | | | | | |
| Applicant may not request that any objection to t | | | | | | | |
| Replacement drawing sheet(s) including the corr | ection is required if the drawing | (s) is objected to. See 37 CFR 1.121(d). | | | | | |
| 11)☐ The oath or declaration is objected to by the | Examiner. Note the attached | d Office Action or form PTO-152. | | | | | |
| Priority under 35 U.S.C. § 119 | | | | | | | |
| 12) Acknowledgment is made of a claim for fore | ign priority under 35 U.S.C. § | } 119(a)-(d) or (f). | | | | | |
| a)⊠ All b)□ Some * c)□ None of: | | | | | | | |
| Certified copies of the priority document | | | | | | | |
| Certified copies of the priority document | ents have been received in A | application No | | | | | |
| 3. Copies of the certified copies of the p | | received in this National Stage | | | | | |
| application from the International Bur | | raccived | | | | | |
| * See the attached detailed Office action for a | list of the certified copies flot | receiveu. | | | | | |
| Attachment(s) | 🗖 · · · | O(DTO 412) | | | | | |
| Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) | none Ne | Summary (PTO-413) (s)/Mail Date | | | | | |
| Notice of Draftsperson's Patent Drawing Review (P10-946) Information Disclosure Statement(s) (PT0-1449 or PT0/SB Paper No(s)/Mail Date | | Informal Patent Application (PTO-152) | | | | | |

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

Claims 5-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent 6,362,515 B2 to Hayakawa.

Regarding claims 5-6, the examiner interprets the word layer to allow for the inclusion of multiple films of different materials. Hayakawa discloses multiple films, including aluminum oxide, aluminum nitride and aluminum oxynitride films, stacked in any combination on a

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substrate, which may be a sapphire substrate (column 4 lines 10-17 and column 6 lines 34-36). The allowed combination of the films from the substrate in the order of alumina and aluminum oxynitride would create a layer of the combined films in which a proportion of N to a composition ratio of N, O, and Al in the first surface (aluminum oxide film) would be smaller than that in the second surface (aluminum oxynitride) as indicated in claims 5-6. Additionally, in the same layer, a proportion of O to a composition ratio of N, O, and Al in the first surface (aluminum oxide film) would be larger than that in the second surface (aluminum oxynitride film). Further, given the multilayer structure of Hayakawa, a cap layer of alumina may be provided and GaN semiconductor layer may be formed over said layer (column 6 lines 62-67). Because Hayakawa discloses the films claimed and discloses that they may be arranged in any manner, it would have been obvious to a person having ordinary skill in the art at the time of the invention to create the claimed structure.

Regarding claims 7-12, Hayakawa discloses multiple films, including aluminum oxide, aluminum nitride and aluminum oxynitride films, stacked in any combination on a substrate, which may be a sapphire substrate (column 4 lines 10-17 and column 6 lines 34-36). This combinability allows for any of the layered structures indicated in claims 7-12. Because Hayakawa discloses all of the films claimed and discloses that they may be arranged in any manner, it would have been obvious to a person having ordinary skill in the art at the time of the invention to create the claimed structures.

Response to Arguments

Examiner acknowledges applicant's amendment to the specification and to claims 5-10

and addition of claims 11-12.

Applicant's arguments with respect to claims 5-11 have been considered but are moot in

view of the new ground(s) of rejection.

Regarding applicant's assertion that Hayakawa does not allow for but prevents crystal

growth, examiner points out that Hayakawa clearly allows for lateral crystal growth as indicated

in column 2.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this

Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a).

Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE

MONTHS from the mailing date of this action. In the event a first reply is filed within TWO

MONTHS of the mailing date of this final action and the advisory action is not mailed until after

the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

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will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Elizabeth Ivey whose telephone number is (571) 272-8432. The examiner can normally be reached on 7:00- 4:30 M-Th and 7:00-3:30 alt. Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Jennifer McNeil can be reached on (571) 272-1540. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Elizabeth D. Ivev

JENNIFER C. MCNEIL SUPERVISORY PATENT EXAMINER

10/29/04